## **CLAIMS**

- 1 1. A process for fabricating a heat sink, comprising:
- 2 providing a heat sink; and
- treating the heat sink to a cryogenic quenching process.

The process of Claim 1 wherein the heat sink is fabricated from a metal alloy having precipitating constituents.

- 3. The process of Claim 1 wherein the heat sink is part of a microelectronic package including a die affixed to a carrier substrate.
- 4. The process of Claim 1 further comprising prior to treating the heat sink to the cryogenic quenching process first treating the heat sink to a temperature high enough to lead to a secondary re-crystallization grain growth, which changes the microstructure of the heat sink from a fine grain to a coarse grain
- 1 5. The process of Claim 1 wherein the treating of the heat sink to the cryogenic
- 2 quenching process includes gradually lowering the heat sink to a cryogenic temperature
- 3 and then immediately raising the temperature of the heat sink.
- 1 6. The process of Claim 4 wherein the changing of the microstructure of the heat
- 2 sink from a fine grain to a coarse grain improves the thermal conductivity of the heat sink

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by reducing the number of grain boundaries in the heat sink that obstruct the movement 3 of atomic and molecular species. 4 The process of Claim 1 further comprising affixing the heat sink to a 7. 1 microelectronic die mounted to a package substrate. 2 A process of fabricating a heat sink, comprising: 8. 1 providing a heat sink comprise of a metal alloy; 2 raising the temperature of the heat sink to cause a secondary re-crystallization 3 grain growth in the metal alloy; and treating the heat sink to a crybgenic quenching process. il. The process of Claim 8 wherein the metal alloy has precipitating constituents. 9. F 1 1 0 The process of Claim 8 wherein the thermal conductivity of the heat sink is 10. improved by changing the microstructure of the metal alloy from a fine grain structure to 3 a coarse grain structure. The process of Claim/8 wherein the heat sink is fabricated from an aluminum 1 11. 2 alloy. The process of Claim 8 wherein the heat sink is fabricated from a copper alloy. 12. 1

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The process of Claim 8 further comprising affixing the heat sink to a 13. 1 microelectronic die mounted to a package substrate. 2 A process of fabricating a heat sink, comprising: 14. 1 providing a heat sink; and 2 expanding the grain structure in the heat sink from a fine grain to a coarse grain to 3 enhance the thermal conductivity of the heat sink. 4 15. The process of Claim 14 wherein the heat sink is fabricated from a metal alloy 1 C) 2 with secondary re-crystallization grain growth. The process of Claim 15 further comprising treating the heat sink to a cryogenic 16. [] |--2 quenching process by gradually lowering the heat sink to a cryogenic temperature and **[]** 3 then immediately raising the temperature. 4) M Q) The process of Claim 14 wherein the heat sink is part of a microelectronic 17. package which includes a die affixed to a package substrate, the thermal conductivity of the heat sink improved by reducing the grain boundaries that obstruct the movement of 3

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atomic and molecular species.